

<b>INFORMATION DISCLOSURE STATEMENT</b>  <i>(Use Several Sheets if necessary)</i>	ATTY DOCKET NO. UTC 008A	SERIAL NO. 10/731, 639
	APPLICANT George, et al.	
	FILING DATE December 9, 2003	GROUP 1773

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB-CLASS	FILING DATE IF APPROPRIATE
X	5,705,265	Jan. 6, 1998	Clough et al.	428	307.3	
	5,271,969	Dec. 21, 1993	Ogura	427	561	
	5,273,942	Dec. 28, 1993	McCauley et al.	501	97	
	5,985,175	Nov. 16, 1999	Fan et al.	252	301.4	
	6,613,383	Sept. 2, 2003	George et al.	427	212	
X	3,647,358		Greenberg			

## FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION YES   NO

## OTHER DISCLOSURES (Including Author, Title, Date, Pertinent Pages, Place of Publication, Etc.)


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04/04

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Initial if citation considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include a copy of this form with next communication to Applicant.

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<b>INFORMATION DISCLOSURE STATEMENT</b>  <i>(Use Several Sheets if necessary)</i>	ATTY DOCKET NO.	SERIAL NO.
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